

# SYNTHESIS OF SI NANOPARTICLES WITH CONTROLLED SIZE, MORPHOLOGY AND CRYSTALLINITY IN A CO<sub>2</sub> LASER PYROLYSIS REACTOR

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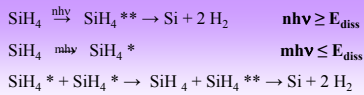
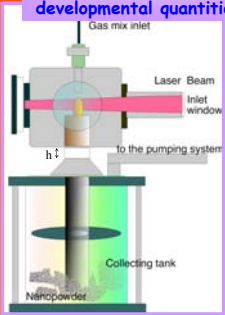
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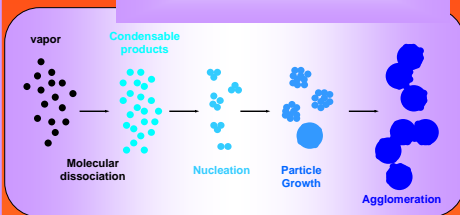
Si-nanocrystals reveal intriguing size-dependent optical properties which could be exploited in a number of fields ranging from optoelectronics to sensors and to bio-imaging.

The most challenging task in preparing Si-nanoparticles is to succeed in controlling the particle size and morphology as well as the surface properties.

CO<sub>2</sub> laser pyrolysis of SiH<sub>4</sub> gas appears as a very flexible tool for the production of Si nanoparticles in developmental quantities



particle nucleation and growth occurs as a consequence of collisions between radicals produced by laser induced dissociation of gas phase precursors



produced nanopowders formed by aggregates of nearly monodispersed primary particles



aggregates held together either by weak bonds (soft agglomerates) or by sintered necks (hard agglomerates).

particle size depends on aggregation

SiH<sub>4</sub> concentration depends on Residence time

To reduce crystalline core: two strategies



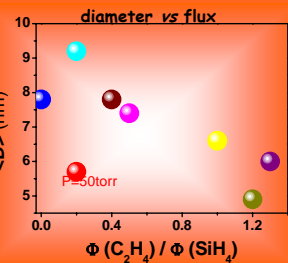
Addition of C<sub>2</sub>H<sub>4</sub> in the inner channel as sensitizer

The role of ethylene is twofold:

- ✓ dilution of the reactive phase and control of the particle growth by decreasing the collisions between radicals;
- ✓ increasing of the average temperature by coupling the laser energy into the system also at the low concentrations of silane.



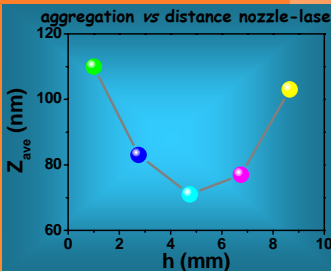
Use of a "quenching" collection system



powders with smaller particle size average diameter  $\leq 6$  nm

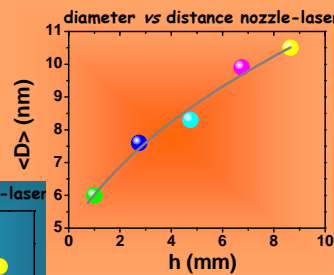
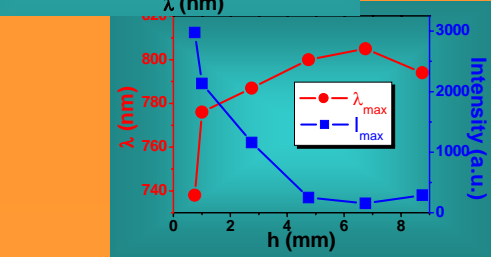
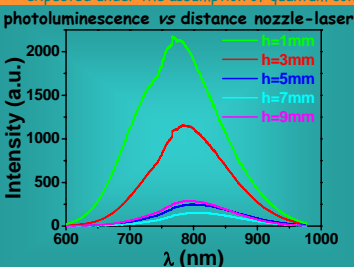
## powder agglomeration

It is estimated by  $Z_{\text{ave}}$  by Dynamic Light Scattering measurements. The aggregate size does not decrease steadily with decreasing residence time in the reactor, as expected when considering the associated reduction of the collision probability. A possible explanation is that the aggregation rate of primary particles is proportional to the concentration of the particles, which could be higher when growth kinetics is stopped at an early stage.



## emission in the red-near-infrared region

A blue shift of the PL maximum is found when the distance collector-laser (and consequently the particle size) decreases, together with the PL intensity increase, as expected under the assumption of quantum confinement.

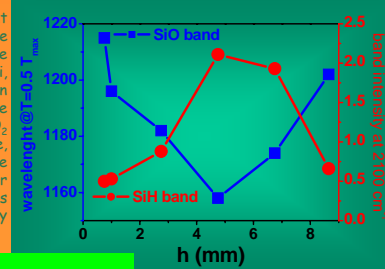
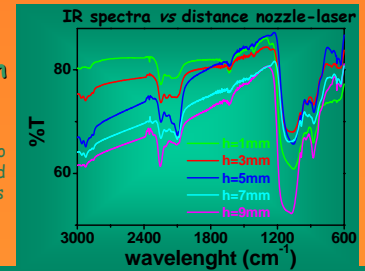


## surface characterization by IR spectra

FTIR spectra are different from sample to sample, pointing out for different amount and quality of the oxide layer capping the particles. The collector position affects:

- ✦ the peaks intensity at 2100 cm<sup>-1</sup> (SiH)
- ✦ the shoulder at 1200 cm<sup>-1</sup> (SiO<sub>2</sub>)

For small and large h both bands indicate larger amount of nearly stoichiometric oxide, while at intermediate values the amount of the oxide is at minimum. The oxidation rate mainly depends on H passivation of Si, which makes the surface resistant to oxidation, and on the presence of strained structures that weaken the Si-Si bonds and cause susceptibility to the attack of O<sub>2</sub> and H<sub>2</sub>O. When powders were collected near the flame, the particles are smaller and so the surface is more strained, resulting in high oxidation rate. On the other hand, when h increases, the oxidation rate increases also, possibly because of poor surface passivation by hydrogen or by increased surface reactivity.



## CONCLUSION

We show how to control and decrease the Si nanoparticle size without a drastic reduction of the productivity by two complementary techniques:

- > addition of a reaction sensitizer (like ethylene) in order to dilute silane without excessive cooling of the system;
- > quenching of the growth process by collecting the nanoparticles at very small distances from the reaction flame.

As a consequence, sizeable quantities of Si nanoparticles with controllable optical properties can be prepared for a wide range of applications.



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